

International guest speaker

Ben L. FERINGA, Chemistry Nobel Prize in 2016, University of Groningen, Netherlands

Plenary lectures

Guy BERTRAND, Member of the French Academy of Sciences, Foreign Member of the Chinese Academy of Sciences, University of California, San Diego, USA

Christophe COPERET, Member of the French Academy of Sciences, ETH Zurich, Switzerland

Marc FONTECAVE, Member of the French Academy of Sciences, Collège de France, Paris

Jean-Marie TARASCON, Membre de l'Académie des Sciences, Collège de France

Florent ALLAIS, URD Agro-Biotechnologies Industrielles (ABI), AgroParisTech, Pomacles-Bazencourt

Aurélié BOULLEGUE-MONDIERE, Bluestar Silicones, Lyon

Céline CHIZALLET, IFP Energies Nouvelles (IFPEN), Lyon

Lorie HAMELIN, Toulouse Biotechnology Institute, INRAE and INSA Toulouse

Sergio MASTROIANNI, SYENSQO, Lyon

Carine MICHEL, Laboratoire de Chimie, Ecole Normale Supérieure de Lyon

Alessandra QUADRELLI, Institut de Recherche sur la Catalyse et l'Environnement de Lyon, CNRS Université Lyon 1

Yunhui WANG, ROQUETTE Frères, Lestrem

Buxing HAN (韩布兴), Academician of the Chinese Academy of Sciences, Institute of Chemistry, Beijing, and East China Normal University, Shanghai

Can LI (李灿), Academician of the Chinese Academy of Sciences, Dalian Institute of Chemical Physics (CAS), Dalian

Licheng SUN (孙立成), Academician of the Chinese Academy of Sciences, Westlake University, Hangzhou

Shi-Gang SUN (孙世刚), Academician of the Chinese Academy of Sciences, Xiamen University

Suojiang ZHANG (张锁江), Academician of the Chinese Academy of Sciences, Henan University, Kaifeng, and Institute of Process Engineering, Beijing.

Dongyuan ZHAO (赵东元), Academician of the Chinese Academy of Sciences, Fudan University, Shanghai

Hong NIE (聂红), Academician of the Chinese Academy of Engineering, Sinopec RIPP, Beijing

Bao-Lian SU (苏宝连), Member of the European Academy of Sciences and the Royal Academy of Sciences of Belgium, Wuhan University of Technology & University of Namur

Haichao LIU (刘海超), Peking University, Beijing

Fengshou XIAO (肖丰收), Zhejiang University, Hangzhou

Peng WU (吴鹏), East China Normal University, Shanghai

Invited lectures

Clément CAMP, CP2M, CPE Lyon

Grégory CHATEL, USMB Chambéry

Laetitia CHAUSSET-BOISSARIE, COBRA, Rouen

Frédéric GUEGAN, IC2MP, Poitiers

Egon HEUSON, UCCS, Lille

Maïwenn JACOLOT, ICBMS, Lyon

Sébastien LIVI, IMP, Lyon

Noémie PERRET, IRCELYON, Lyon

Léa VILCOCQ, IRCELYON, Lyon

Marie VUILLEMIN, ICBMS, Lyon

Songbo HE (何松波), DICP, Dalian

Chengeng LI (李晨耕), BUCT, Beijing

Longfei LIN (林龙飞), ICCAS, Beijing

Yue LIU (刘玥), ECNU, Shanghai

Qingqing MEI (梅清清), Zhejiang University

Bo PENG (彭博), Sinopec RIPP, Beijing

Yang SONG (宋洋), Sinopec RIPP, Beijing

Gaixiu YANG (杨改秀) Xizang

Dawei ZHANG (张大卫), ECNU, Shanghai

Wei ZHANG (张伟), ECNU, Shanghai

Industrial Roundtable

Representatives from Syensqo, Activation, Roquette, IFPEN, Bluestar Silicones, Wanhua Chemical